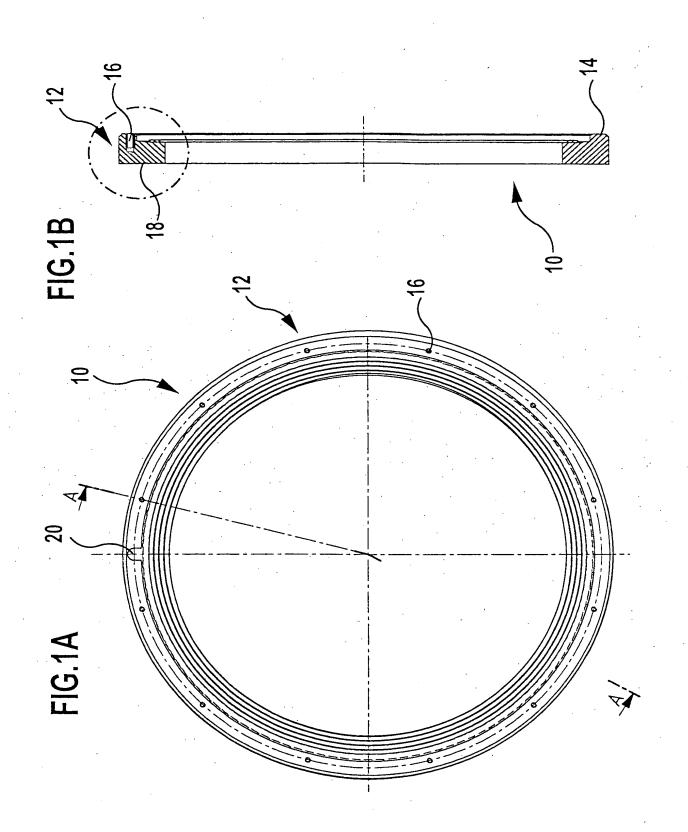
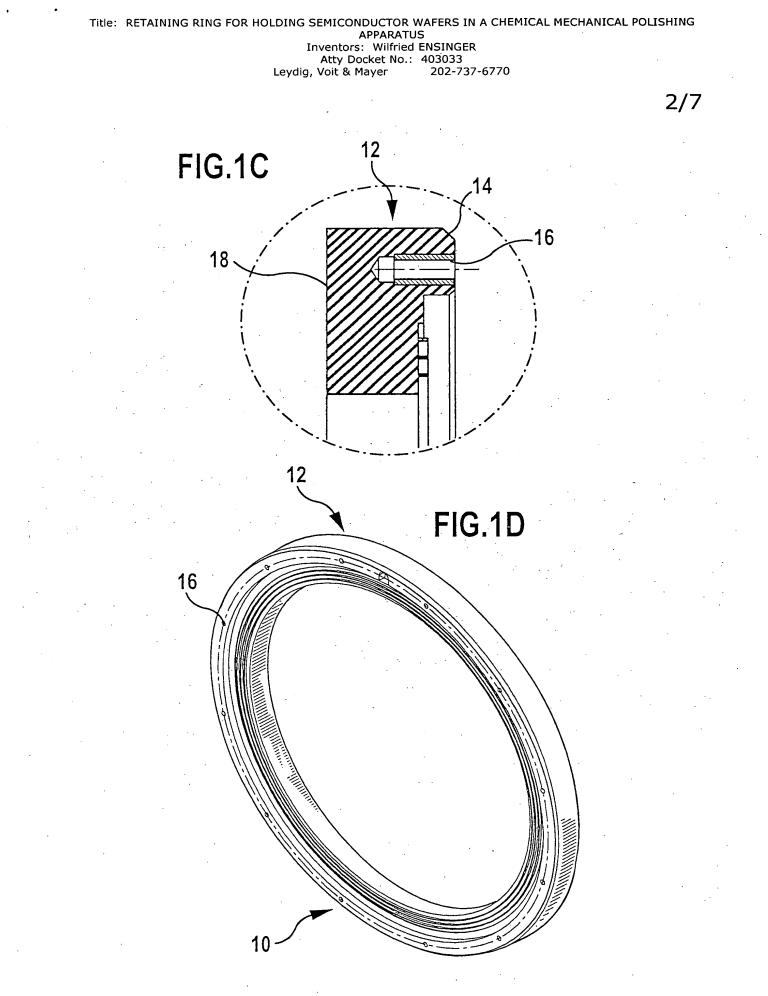


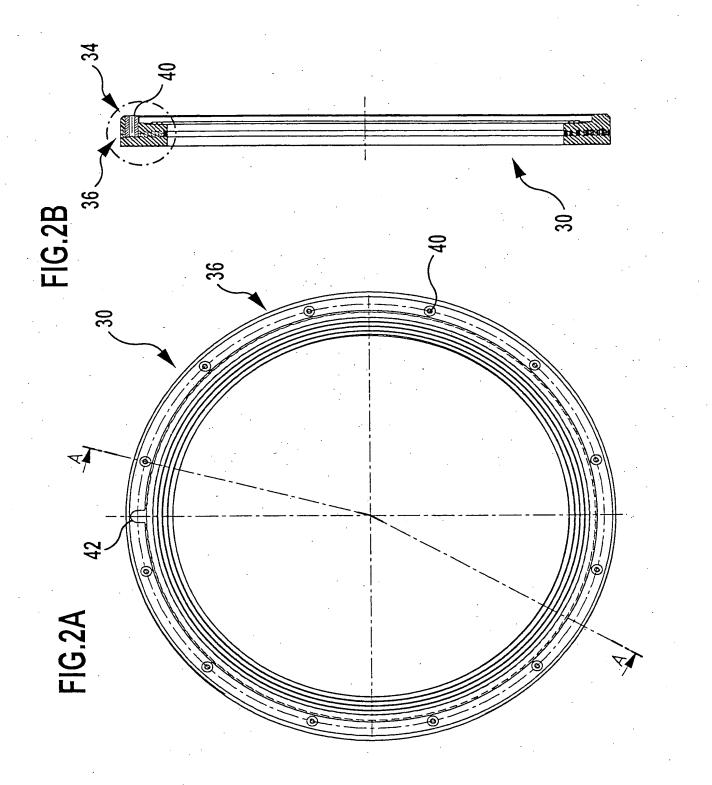
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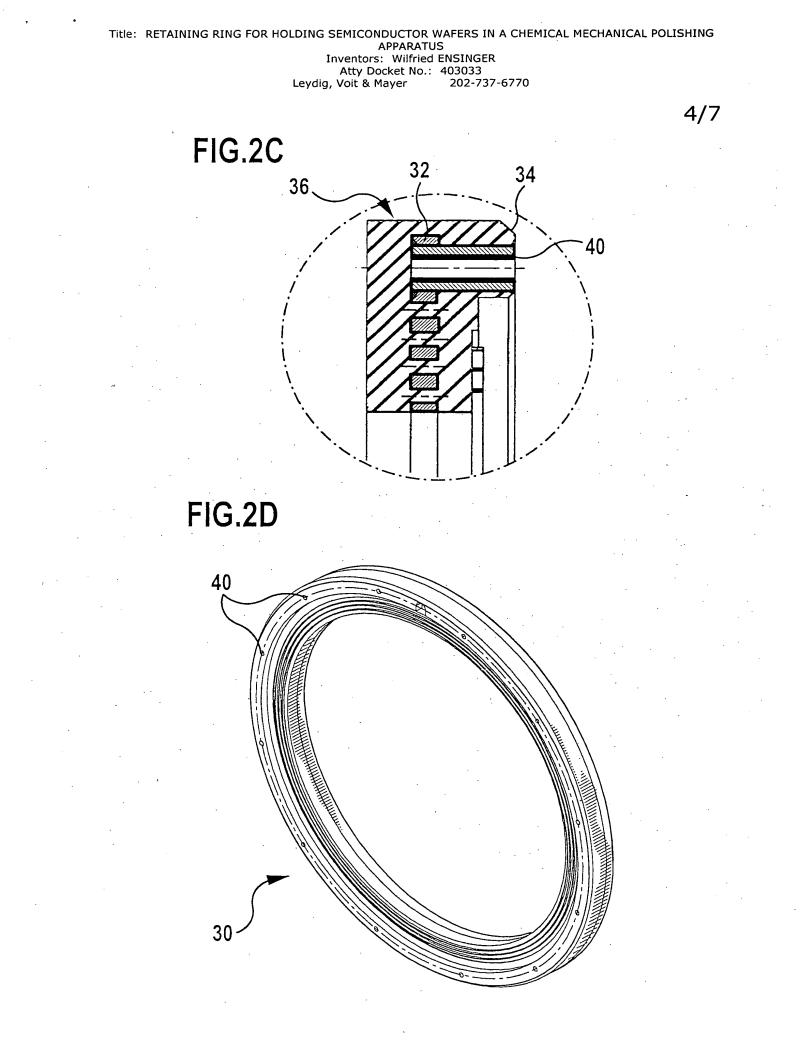


Title: RETAINING RING FOR HOLDING SEMICONDUCTOR WAFERS IN A CHEMICAL MECHANICAL POLISHING APPARATUS Inventors: Wilfried ENSINGER Atty Docket No.: 403033 Leydig, Voit & Mayer 202-737-6770

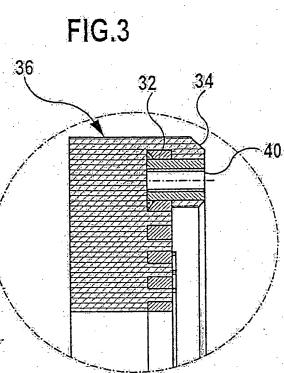
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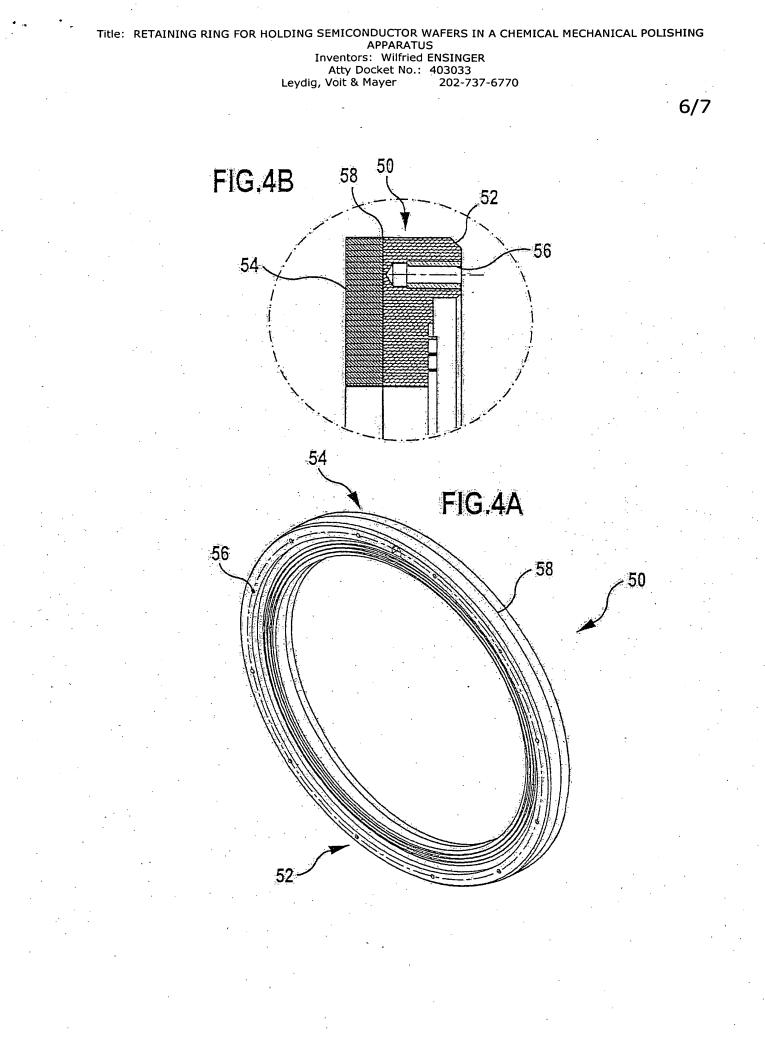
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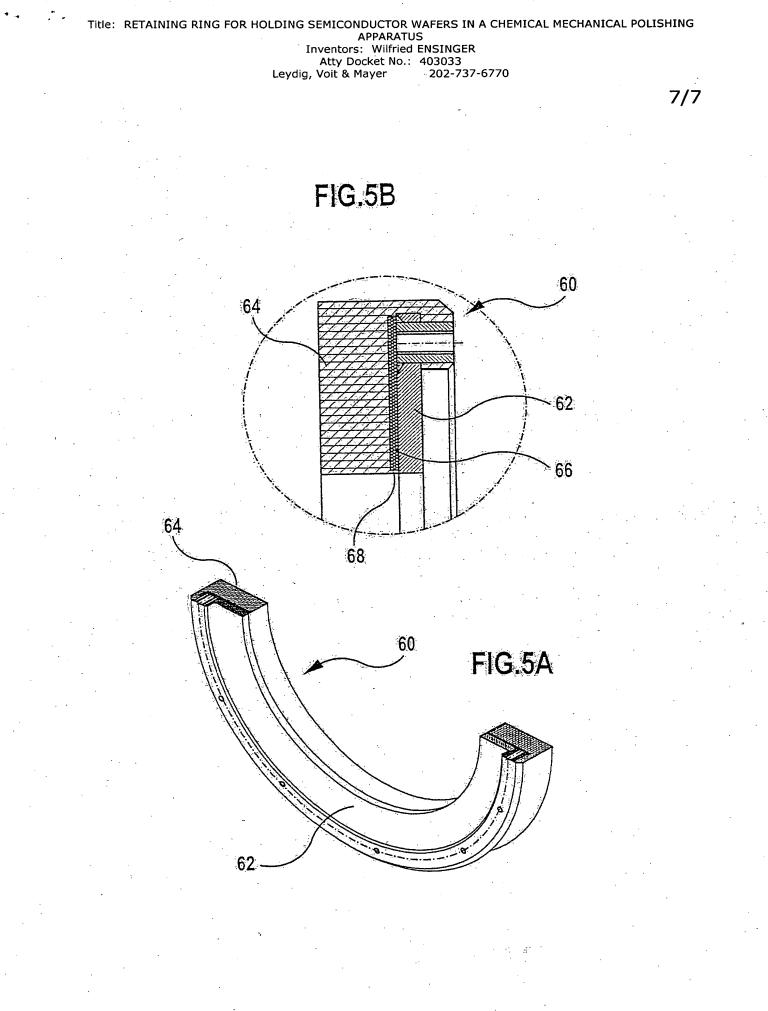


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